Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	28681	SAC or "self aligned contact"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/22 14:12
L3	277	(hardmask or "hard mask") and (ARC or "anti reflective") and (SiN or "silicon nitride") and plug	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/22 14:40
L4	359	(hardmask or "hard mask") and (ARC or "anti reflective") and plug	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/22 14:47
L5	74	4 and 1	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/22 14:40
L6	3638	(hardmask or "hard mask" or SiN or "silicon nitride") and (ARC or "anti reflective") and plug	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/22 15:23
L7	174	1 and 6	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/22 14:48
L8	1	"6376304".PN.	USPAT; USOCR	OR	OFF	2005/08/22 15:14
L9	1	"6353269".PN.	USPAT; USOCR	OR	OFF	2005/08/22 15:14
L10	330	(hardmask or "hard mask" or SiN or "silicon nitride") same (ARC or "anti reflective") same plug	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/22 15:19

L11	527	(hardmask or "hard mask" or SiN or "silicon nitride") and (ARC or "anti reflective") and (plug or contact) and "etch back"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/22 15:36
L12	24	lee-min-suk.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/22 15:37
L13	70	lee-sung-kwon.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/22 15:37